

Additions and Corrections

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Highly Regioselective Diels–Alder Reactions toward Or-
oidin Alkaloids: Use of a Tosylvinyl Moiety as a Nitrogen
Masking Group with Adjustable Electronics.

Page 1681, ref 20. We inadvertently omitted the following
references that describe prior use of the Tsv protecting group
for thiol protection: (a) Arjona, O.; Medel, R.; Rojas, J.;
Costa, A. M.; Vilarrasa, J. *Tetrahedron Lett.* **2003**, *44*, 6369.
(b) Arjona, O.; Iradier, F.; Medel, R.; Plumet, J. *J. Org.*
Chem. **1999**, *64*, 6090. We thank Prof. Villarrasa for bringing
this to our attention.

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